INTERNATIONAL STANDARD

ISO 10110-12

Third edition 2019-11

Optics and photonics — Preparation of drawings for optical elements and systems —

Part 12: **Aspheric surfaces**

> Optique et photonique — Préparation des dessins pour éléments et aces asphe systèmes optiques —

Partie 12: Surfaces asphériques





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Published in Switzerland

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Foreword

ISO (the International Organization for Standardization) is a worldwide federation of national standards bodies (ISO member bodies). The work of preparing International Standards is normally carried out through ISO technical committees. Each member body interested in a subject for which a technical committee has been established has the right to be represented on that committee. International organizations, governmental and non-governmental, in liaison with ISO, also take part in the work. ISO collaborates closely with the International Electrotechnical Commission (IEC) on all matters of electrotechnical standardization.

The procedures used to develop this document and those intended for its further maintenance are described in the ISO/IEC Directives, Part 1. In particular, the different approval criteria needed for the different types of ISO documents should be noted. This document was drafted in accordance with the editorial rules of the ISO/IEC Directives, Part 2 (see www.iso.org/directives).

Attention is drawn to the possibility that some of the elements of this document may be the subject of patent rights. ISO shall not be held responsible for identifying any or all such patent rights. Details of any patent rights identified during the development of the document will be in the Introduction and/or on the ISO list of patent declarations received (see www.iso.org/patents).

Any trade name used in this document is information given for the convenience of users and does not constitute an endorsement.

For an explanation of the voluntary nature of standards, the meaning of ISO specific terms and expressions related to conformity assessment, as well as information about ISO's adherence to the World Trade Organization (WTO) principles in the Technical Barriers to Trade (TBT) see www.iso.org/iso/foreword.html.

This document was prepared by Technical Committee ISO/TC 172, *Optics and photonics*, Subcommittee SC 1, *Fundamental standards*.

This third edition cancels and replaces the second edition (ISO 10110-12:2007), which has been technically revised. It also incorporates the Amendment ISO 10110-12:2007/Amd.1:2013.

The main changes compared to the previous edition are as follows:

- a) The document has been updated with respect to surface form tolerances as described in ISO 10110-5.
- b) The reference to the new part ISO 10110-19 has been added.
- c) The document has been restructured.
- d) A few surface descriptions have been added.

A list of all the parts in the ISO 10110 series can be found on the ISO website.

Any feedback or questions on this document should be directed to the user's national standards body. A complete listing of these bodies can be found at www.iso.org/members.html.

Optics and photonics — Preparation of drawings for optical elements and systems —

Part 12:

Aspheric surfaces

1 Scope

This document specifies rules for presentation of aspheric surfaces and surfaces with low order symmetry such as cylinders and toroids in the ISO 10110 series, which standardizes drawing indications for optical elements and systems. It also specifies sign conventions and coordinate systems.

This document does not apply to off-axis aspheric and discontinuous surfaces such as Fresnel surfaces or gratings.

NOTE For off-axis aspheric and non-symmetric surfaces, see ISO 10110-19.

This document does not specify the method by which conformity with the specifications is tested.

2 Normative references

The following documents are referred to in the text in such a way that some or all of their content constitutes requirements of this document. For dated references, only the edition cited applies. For undated references, the latest edition of the referenced document (including any amendments) applies.

ISO 1101:2017, Geometrical product specifications (GPS) — Geometrical tolerancing — Tolerances of form, orientation, location and run-out

ISO 10110-1, Optics and photonics — Preparation of drawings for optical elements and systems — Part 1: General

ISO 10110-5, Optics and photonics — Preparation of drawings for optical elements and systems — Part 5: Surface form tolerances

ISO 10110-6, Optics and photonics — Preparation of drawings for optical elements and systems — Part 6: Centring tolerances

ISO 10110-7, Optics and photonics — Preparation of drawings for optical elements and systems — Part 7: Surface imperfections

 ${\tt ISO~10110-8,\,Optics~and~photonics-Preparation~of~drawings~for~optical~elements~and~systems-Part~8:}\\ Surface~texture$

3 Terms and definitions

No terms and definitions are listed in this document.

ISO and IEC maintain terminological databases for use in standardization at the following addresses:

- ISO Online browsing platform: available at https://www.iso.org/obp
- IEC Electropedia: available at http://www.electropedia.org/